



45681

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

|                              |   |                       |
|------------------------------|---|-----------------------|
| In re Application of         | : |                       |
| Michael K. DENK et al.       | : | Art Unit: 1762        |
| Serial No.: 10/643,090       | : | Examiner: K. Stouffer |
| Filed: August 19, 2003       | : |                       |
| For: A NEW CLASS OF VOLATILE | : |                       |
| COMPOUNDS FOR THE DEPOSITION | : |                       |
| OF THIN FILMS OF METALS AND  | : |                       |
| METAL COMPOUNDS              | : |                       |

**AMENDMENT AND  
RESPONSE TO RESTRICTION REQUIREMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the September 20, 2006 Office Action, please amend the above-identified application as follows.

11/21/2006 SZEWDIE1 00000138 10643090

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